Proceedings of the International Workshop on Smoothing and Characterization of Magnetic Films for Advanced Devices Kraków, Poland, July 4–6, 2007

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Preface

The Workshop on Smoothing and Characterization of Magnetic Films for Advanced Devices was organized in Kraków, Poland, by the Faculty of Physics and Computer Science at the AGH — University of Science and Technology. The meeting as a part of 6FP "Ultrasmooth" network aimed for disseminating among the large scientific community the knowledge of state of the art in smoothing and characterization techniques for magnetic films in advanced devices. In total over 60 colleagues from 11 countries participated in the workshop. There were 7 invited talks and 50 contributed, both oral and poster presentations.

This issue of $Acta\ Physica\ Polonica\ A$ is a collection of publications from a selected invited talks and contributed papers presented during the workshop.

The financial support of the European Unions Marie Curie actions (Research Training Networks) ULTRASMOOTH under contract MRTN-CT-2003-504462 is kindly acknowledged.

Tomasz Ślęzak (Editor of the Proceedings)

Invited papers presented during workshop

- 1. Józef Barnaś, Poznań, Poland Spin dependent phenomena in magneto-electronic devices.
- 2. Russell Cowburn, London, UK Nanomagnetic logic devices.
- 3. Thibaut Devillers, Grenoble, France Structural and magnetic properties of self-assembled $Ge_{1-x}Mn_x$ nanocolumns.
- 4. Tomasz Dietl, Warsaw, Poland Ferromagnetic semiconductors as spintronics materials.
- 5. Jaroslav Fabian, Regensburg, Germany Semiconductor spintronics device schemes.
- 6. Paola Luches, Modena, Italy Arrays of metal nanostructures produced by focused ion beam.
- 7. Katharina Theis-Bröhl, Bochum, Germany Preparation of magnetic films and nanostructures.